

ThermoFisher SCIENTIFIC

Scios Dual Beam

Module 1

- High-Current 65 nA Ion Column (with Automated Apertures): Fast milling of large areas
- Drift Suppression (DS) mode Accurate milling of non-conductive material
- Large sample holder
- New NiCol e-column with Trinity detection
- High-Current FE-Column; 200 nA (with Automated Apertures):
 - Expanding High Resolution SE imaging at high and low beam currents
 - Accurate and fast milling of non-conductive material
 - Fast EDS and EBSD analysis
- Flexible Port configuration
- New LVSED: Low Vacuum SE detector: Charge-free imaging of non-conductive materials



- Retractable Annular STEM 3+ detector: Bright Field, Dark Field and High Angle Dark Field
- Retractable DBS (for High Vacuum and Low Vacuum)
- T3 in column detector
- ICE: Ion Conversion and Electron detector
- EasyLift manipulator



SDB = (small) Dual Beam system = SEM and FIB Column on one system





- DualBeam system unique functions
 - Imaging with both beams
 - Slice with FIB and view with SEM (simultaneously=SPI)
 - In-situ cross sectioning, etching & coating
 - Electron beam metal deposition for protection
 - Electron beam for charge neutralization
 - Thin TEM sample preparation (<100nm) with low kV cleaning
 - Site specific sample preparation and EDS



Imaging with both beams

- SEM: SE imaging, BSE imaging, X-ray analyses
- •FIB: SE imaging, SI imaging, SIMS
- Secondary ion imaging shows material contrasts
- Channeling Contrasts with I beam (or E beam)





4 GIS ports



EasyLift



Cryo



Micro Analysis





Large Sample holder, Multiple Options, Easy Navigation



Bulk samples and pre-tilted TEM grids can be loaded simultaneously. Allowing S(TEM) sample preparation and STEM without breaking the vacuum

- Multiple positions accommodate plenty of samples
- Pre-tilted sample positions for Bulk Samples
- Large Stage movement; 110mm x 110 mm X,Y, 90° tilt
- Vertical, Horizontal and Pre-tilted TEM grid holder positions
- Easy and Fast sample Location with Nav-Cam



Scios : FEI Dual Beam





Principle of a Dual Beam







FIB

- i-beam deposition
- Adds and Removes Material: site specific
- SE imaging
- Secondary Ion imaging
- In situ sample prep
- Resolution: 5nm @ 30kV
- Combines high magnification imaging and sample modification
- Ion beam penetration: 50nm in AI @ 30kV (6nm @1kV) more surface info

SEM

- e-beam deposition
- Adds Material: site specific
- SE imaging
- BSE imaging
- X-ray analyses
- Dynamic experiments
- Better resolution: 1nm @ 30kV
- e beam penetration:
 6000nm in AI @ 30 kV
 (28nm @ 1kV)





•FIB removes small amount of material leaving a perpendicular wall for imaging (with e-beam or i-beam)
•SEM takes image of revealed structures below the surface to image/measure

the previously buried feature



The most commonly used ion is Gallium:

- it has the longest liquid range of any metal (from 29.8°C to 2175°C)
- providing room temperature operation
- yields a long lifetime source
- Gallium can be focused to a very fine probe size (< 10 nm in diameter)
- Liquid metal Gallium is high vacuum compatible
- large ions for physical sputtering
- (below the melting point) Gallium is a soft, silver white metal that is stable in both air and water.



The GIS or Gas Injection system enables:

- Deposition of a metal or insulator
- FIB or SEM assisted chemical vapor deposition
- Etching chemistries, preferential or enhanced milling





Some examples







Imaging Cross section



BSE image: compositional info



30 µs

Quanta 3D FEG

30.00 kV 19.0 mm 50 pA 8 000 x



SE image: topographical info

Ion induced SE image: crystallographic orientation contrast



Elemental mapping of cross section





In-situ lift out TEM sample preparation



(a)

(b)

(a) Rough milled TEM specimen by FEI AutoTEM;(b) After bottom and sides cut the specimen is ready for in-situ lift out.



In-situ lift out TEM specimen preparation



(a)



(b)

(a) In-situ lift out Probe needle connected to the specimen by ion beam Pt deposition;(b) (b) The specimen was cut free from the bulk material and in-situ lifted.

In-situ lift out TEM specimen preparation





(b)

(a)

(a) The in-situ lifted specimen transferred to a TEM grid

(b) The specimen was connected to the TEM grid by ion beam Pt deposition and the

needle was cut free from the specimen.

The specimen is ready for final thinning.



Images made after final thinning



SEM se images

SEM/STEM BF images



More examples:

Nano Prototyping:
DBs milling and deposition from Micro- to Nano-meter scale







Point source for laser-light emission produced by milling the circular structure but leaving the spot in the middle intact which then acts as a point source for laser-light emission 70 nm optical transparent SiOx on ZnCdSe and ZnSe



FIB Micro/Nano milling: AFM Diamond Tips













FIB Micro/Nano W-deposition



Intrinsic ferroelectrics single crystal Lithium Niobate (LiNbO₃): Using FIB to direct write of metal line onto the side walls of the LiNbO₃



Slice and View result; Set of images





3D reconstruction and visualization



Otho-slices of an aligned dataset of Arabidopsis







